Flow of thin liquid lm s on chem ically structured substrates

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A bstract

Chem ically patterned surfaces are of signi cant interest in the context of m icro uidic applications. M iniaturization of such devices will eventually lead to structures on the nano-scale. W hereas on the m icron scale purely m acroscopic descriptions of liquid ow are valid, on the nanom eter scale long-ranged inter-m olecular interactions, them al uctuations such as capillary waves, and nally the m olecular structure of the liquid becom e im portant. W e discuss the m ost in portant conceptual di erences between ow on chem ically patterned substrates on the m icron scale and on the nanom eter scale. These concern the structure of the triple line, the type of interactions between neighboring liquid ow s, and the in uence of them olecular structure of the liquid on the ow . W e form ulate four design issues for nano uidics related to channel width, channel separation, and channel bending radius, and conclude with a discussion of the relevance of the conceptual di erences between the m icron scale and the nanom eter scale for these issues.

1 Introduction

In recent years substantial e orts have been invested in miniaturizing chemical processes by building micro uidic systems. The \lab on a chip concept" integrates a great variety of chemical and physical processes into a single device [14, 24, 27] in a similar way as an integrated circuit incorporates many electronic devices into a single chip. These micro uidic devices do not only allow for cheap mass production but they can operate with much smaller quantities of reactants and reaction products than standard laboratory equipments. This is particularly important for rare and expensive substances such as certain biological substances and for toxic or explosive materials. Even though most available micro uidic devices today have micron sized channels further miniaturization is leading towards



Figure 1: Schem atic picture of liquid ow guided by so-called chem ical walls on a chem ically patterned substrate. The liquid moves along lyophilic stripes (light grey) on a lyophobic substrate (dark grey). The liquid layer ends in a three-phase contact line and a liquid monolayer (the precursor lm) spreads ahead of it.

the nano-scale. Besides meeting technical challenges, new theoretical concepts are needed to understand the basic physical processes underlying this new technology. W hereas the ultimate limits for the miniaturization of electronic devices are set by quantum uctuations, in a chemical chip these limits are determined by thermal uctuations and can be explored by methods of classical statistical mechanics.

There are twom ain lines of developm ent form icro uidic systems. The rst one encom passes system s with closed channels. A common technique to produce these devices is to cast poly (dim ethylsiloxane) (PDMS) over a topographically structured master, to peel o the polymer after curing, and to seal the resulting topographically structured material onto a at surface. This way rather complicated devices including valves and pumps have been fabricated [16]. However, closed channel systems have the disadvantage that they can be easily clogged by solute particles such as colloids or large bio-polymers.

The second type of system s are open with a free liquid-vapor interface and the uid is not con ned by physical but by chem ical walls. The idea is that the liquid will be guided by lyophilic stripes on an otherwise lyophobic substrate. There are two sub-types of this technique: using a single chem ically patterned substrate [8, 12] (see also Fig. 1) or a chem ically patterned slit pore [15, 21, 29], respectively. The substrate surfaces can be structured chem ically by printing or photographical techniques. All the techniques are con ned to two dimensions.

Liquids in contact with chem ically structured substrates are not only of technological use but also enjoy high interest in basic research. Wetting on chem ically structured substrates has been studied extensively on all length scales. For example adsorption on stripe patterns shows a rich morphology on the macro-scale [22, 6] as well as on the nano-scale [10, 4]. In this context ow of liquids has also been studied to a large extend. Most of this research has been focused on hom ogeneous substrates, in

particular on dynamic contact angles, dewetting of thin lms, and ow of thin lms in many circum stances. For a review see Ref. [25].

In the following we rst describe brie y those equilibrium features of wetting on chemically patterned substrates which are most relevant for micro uidic applications. A fler discussing the characteristics of thin lm ow on hom ogeneous substrates, we state the three main conceptual di erences between micro-scale and nano-scale uid transport in chem ical channels. We conclude with formulating four design principles for nano uidic devices.

2 W etting on chem ically patterned substrates

Equilibrium wetting phenom ena on chem ically patterned substrates have been analyzed theoretically in great detail on both the m acroscopic and the m icroscopic scale. M icroscopic theories, such as the successful density functional theory, take into account the nite range of inter-m olecular attractions and short-ranged repulsions explicitly [11]. D ensity functional theories do not only allow to study the order of wetting transitions and the equilibrium shape of the wetting Im but also the detailed m icroscopic structure of the liquid in the vicinity of the substrate and at the liquidvapor interface [9].

In m acroscopic theories, how ever, the inter-m olecular interactions are approxim ated by local descriptions. For a wetting lm this m eans that the free energy of the lm is described by a bulk term proportional to the volume of the uid, a surface tension term proportional to the area of the liquid-vapor interface, an interface term proportional to the area of the liquid-substrate interface, and a line tension term proportional to the length of the three phase contact line between liquid, vapor, and substrate. In m ost studies the line tension term is neglected. M acroscopic theories have been used to describe the shape of droplets on hom ogeneous and structured substrates [22, 6]. The equilibrium droplet shape in chem ically patterned slit-like pores has also been studied with the same technique [28].

It is a great challenge to describe the interm ediate scale between the m icroscopic and the m acroscopic one. In m ost cases it is impossible to obtain analytical results from m icroscopic theories and num erical calculations are prohibitive for large systems. Current research focuses on extending the scope of m acroscopic theories down to the m eso-scale by incorporating m icroscopic e ects such as the wave-length dependence of the surface tension [23] and detailed properties of the three phase contact line [1].

3 Flow of thin liquid lm s

F low of thin liquid lm s on hom ogeneous substrates has been studied extensively, in particular the motion of the three-phase contact line, dew etting of thin lm s, the stability of falling liquid lm s, and M arangoni ow. A part from a few m olecular dynam ics sim ulations, in m ost studies the liquid ow is described in terms of m eso-scale hydrodynam ics. This m eans that the hydrodynam ic equations are augmented with long-ranged liquidsubstrate interactions and hydrodynam ic slip of the liquid at the substrate (with slip lengths on the nanom eter scale). For a review see R ef. [25]. In a phase-eld description even compressibility e ects and the nite width of the liquid-vapor interface have been taken into account [26]. The nite interface width in the phase eld models is the only signature of therm al uctuations taken into account in hydrodynam ic thin lm models up to now.

The main analytic tool in this approach is the so-called lubrication approximation, which is a small-gradient expansion for the lm thickness and which leads to a fourth order in space, rst order in time parabolic partial di erential equation for the lm thickness. This equation is also often referred to as the thin lm equation and it has been successful in describing dewetting processes quantitatively [5]. Flow over chemical substrate inhom ogeneities has been studied in the context of dewetting of unstable lm s [17] but to little extent for the actual situations relevant to m icro uidics and nano uidics [7, 19].

4 Conceptualdi erences in m icro uidics and nano uidics

In this section we state three important conceptual di erences between micro uidics and nano uidics.

4.1 Triple line and chem ical steps

O ne of the most critical issues in open m icro uidic systems is to keep the liquid in the desired areas such as channels, reactors, and reservoirs. O n a m acroscopic scale the liquid will stay on the lyophilic channels for low

lling and the three phase contact line will lie on the channel area or it will be pinned at the chem ical step. Spill-over onto the lyophobic areas occurs once the contact angle of the liquid at the chem ical step exceeds the advancing contact angle $_{\rm a}$ on the lyophobic area (which is in general larger than the equilibrium contact angle $_{\rm e}$ due to surface defects).

On the nano-scale the situation is quite di erent. First, the concepts of a contact line and contact angle have to be revised. A sharp contact line is replaced by a smooth transition from a mesoscopic wetting lm to the precursor lm [4, 18, 13, 2, 3] which is only some few molecular diam eters thick and spreads ahead of the main portion of the moving liquid. Moreover even an atom ically sharp boundary between lyophilic and lyophobic areas on the substrate will lead to a smooth lateral variation of the interaction potential between the liquid particles and the substrate.

Thus the macroscopic and sharp criterion for a liquid staying on a chem ical channel, namely whether the triple line crosses the channel boundary or not, becomes fizzy at the nano-scale. Since there is always a certain am ount of liquid on the lyophobic part of the substrate, one has to address



F igure 2: Spill-over of a liquid channel on a m icron-sized chem ical strip (left colum n) as compared to a nano-scale strip (right colum n). D ark grey m arks the lyophobic areas and light grey the lyophilic areas. At the m icron scale one can clearly distinguish between no spillage (a) and spillage (c), whereas for nano-channels one can only distinguish between sm all tails (b) and large tails (d) of the lateral liquid distribution.

the issue which fraction of the liquid is outside the channels rather than whether there is liquid outside the channels.

4.2 Interaction between neighboring channels

The question of spillage is of course closely related to the question of interaction between neighboring channels. M acroscopically (neglecting evaporation and recondensation) two neighboring channels will interact once the two liquid lmsmerge. One has to keep in mind that in a m acroscopic description an empty and a lled channel next to each other (Fig. 3(e)) or two lled but not interacting channels (Fig. 3(a)) can be m etastable states. In the rst case two equally lled channels and in the second case a liquid bridge can be the equilibrium state. How such con gurations are a ected by ow has not been investigated yet.

On the nano-scale, how ever, tails of the liquid from two neighboring channels can leak onto the lyophobic area between the channels. If the channels are too close these tails will overlap and thus form a bridge (see Fig. 3 (b) and (d)). Liquid can ow through such a bridge and particles immersed in the uid can di use through these bridges. Thus keeping the two ows separated is a question of time-scales and not a question that can be answered de nitively.

A loo the presence of a monom olecular precursor lm on the lyophobic area can lead to an exchange of molecules (see Fig. 3 (f)). Macroscopically this is certainly negligible but since the ratio between the lm thickness in the channel and the thickness of the precursor lm can be of the order



Figure 3: Interaction between neighboring channels at the micron scale (left colum n) and at the nano-scale (right colum n). Dark grey marks the lyophobic areas and light grey the lyophilic areas. At the micron scale the ow's are either well separated (a) or merged (c). Even a led channel next to an empty one (e) is possible. At the nano-scale the tails of the liquid in the channels will merge and thus form a thin (b) or thick (d) bridge through which material can be interchanged. The thickness of the bridge is that of a monolayer in the case of a precursor lm (f).



Figure 4: On the micron scale (a) the ow can be described hydrodynam ically, i.e., the liquid is described by the local ow eld u (r;t), the local pressure p(r;t), and the density (r;t). On the nano-scale (b) the atom ic structure of the uid and the substrate cannot be ignored [20].

of 10, this can be signi cant at the nano-scale.

Fluctuations also become more important at small scales. In the absence of a precursor lm on the area between the channels, a lled channel next to an empty one can be a metastable state as in the macroscopic case discussed above. But the energy barrier which has to be overcome to connect the two channels is much smaller than for macroscopic distances and much smaller uctuations of the lm height are needed.

Not only the liquid-substrate interactions but also the liquid-liquid interaction has a range of up to 100 nm. Thus the direct interaction between liquid streams in parallel channels will in uence the ow and also the therm al uctuations.

4.3 Flow and the atom istic structure of liquids

The conclusions in the last two subsections are mostly based on quasistatic considerations. Transport mechanisms and dynam ic properties have not been discussed. Experience tells that down to length scales of about 1{10 nm hydrodynam ic theories provide a quite good description of liquid ow. However, even at the micron scale atom istic properties of the liquid show up via the slip length at the liquid-substrate interface and via the details of the regularization of the stress singularity at the moving triple line (see Fig. 4(a)).

In nano uidic systems there is a window of length scales within which long-ranged interm olecular forces play a role and hydrodynamics is still applicable. This window is centered around lm thicknesses of about 100 nm. Below this length scale the atom istic structure of the liquid com es into play. Currently only molecular dynam ics simulations explore this atom ic length scale region (see for example Fig. 4(b)).

5 Design issues for nano uidics

For liquid ow inside chem ically patterned m icron-sized channels several design issues have been addressed [29]. Due to the conceptual di erences between ow on the m icron scale and ow on the nano-scale the answers given for the m icron scale cannot be transferred directly to the nano-scale. How ever, the basic issues are the sam e: (1) How m uch liquid can a chem ical channel contain before considerable spillage onto the lyophobic areas occurs? (2) How wide must the channels be to support ow? (3) How sm all can the radius of curvature of bends in the channel be? (4) W hat is the m inim um distance between liquid stream s below which they interact?

In m icron scale channels these issues can be addressed by considering only surface tensions, contact angles, and line tensions. On the nano-scale the situation is m ore com plex. In particular the details of the interaction between liquid and substrate, the interaction am ong the liquid m olecules, the in uence of the atom istic structure of the uid on the transport properties, and therm al uctuations have to be taken into account in addition.

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